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TC 1700

PATENT  
30205/37328

1752

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Min Ho Jung et al.

Serial No.: 09/878,803

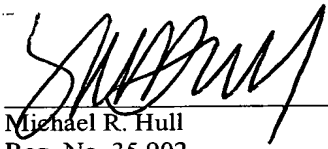
Filed: June 11, 2001

For: Additive for Photoresist  
Composition for Resist Flow Process

Group Art Unit: 1752

Examiner: Yvette C. Thornton

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on August 19, 2003, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450

  
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9/a  
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AMENDMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

Please enter the following amendment in the above-referenced patent application.